

Resource Summary Report

Generated by T1D on Aug 3, 2026

Harvard CNS Nanofabrication Facility

RRID:SCR_009832

Type: Tool

Proper Citation

Harvard CNS Nanofabrication Facility (RRID:SCR_009832)

Resource Information

URL: <http://harvard.eagle-i.net/i/00000130-756e-db1e-1971-4f2080000000>

Proper Citation: Harvard CNS Nanofabrication Facility (RRID:SCR_009832)

Description: Core facility that provides the following services: Nanofabrication cleanroom and instrumentation access, instrument training, staff assistance. The Center for Nanoscale Systems' Nanofabrication Facility (CNS-NF), offers resource and staff support for fabricating and characterizing nanoscale devices and structures. The facility currently operates the 10,000 sq.ft. LISE Cleanroom with leading-edge equipment capable of electron-beam and optical lithography, physical and chemical vapor deposition, dry and wet processing, metrology, and device characterization.

Resource Type: core facility, service resource, access service resource

Keywords: fabrication

Resource Name: Harvard CNS Nanofabrication Facility

Resource ID: SCR_009832

Alternate IDs: nlx_156302

Alternate URLs: <http://www.cns.fas.harvard.edu/facilities/nanofabrication.php>

Record Creation Time: 20220129T080255+0000

Record Last Update: 20260801T191153+0000

Ratings and Alerts

No rating or validation information has been found for Harvard CNS Nanofabrication Facility.

No alerts have been found for Harvard CNS Nanofabrication Facility.

Data and Source Information

Source: [SciCrunch Registry](#)

Usage and Citation Metrics

We have not found any literature mentions for this resource.